


Extracting correlation length in Mott insulators by strong-field driving

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The breakdown of a Mott-insulator when subjected to intense laser fields is characterized by the formation of doublon-hole pairs. This breakdown is furthermore evidenced by the production of high harmonics that can be experimentally measured. Here, we present an approach for extracting the doublon-hole correlation length of a Mott insulator. The method is based on a dynamical calculation of the Mott insulator's rate of charge production in response to an applied strong-field laser pulse. We find that coupling the Mott insulator to a metal drastically increases the correlation length, in support of our recent hypothesis [Phys. Rev. B 108, 144434 (2023)] that coupling to a metal enhances the charge fluctuations in the insulator. We confirm our conclusions using density matrix renormalization group (DMRG) calculations. The proposed method can be applied to experimentally measured observables, such as differential reflectivity or the high harmonic generation (HHG) spectrum to extract doublon-hole correlation length. © 2024 Optica Publishing Group

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1. INTRODUCTION

Since the advent of the laser and its subsequent application to probe states of matter, the theoretical study of strong-field physics has quickly gained momentum. The framework developed by Keldysh [1] is generally accepted as the basic model describing the ionization of atoms and solid media under the influence of strong electromagnetic fields with frequencies lower than the ionization potential [2–5]. Keldysh realized that strong-field ionization can be understood as a consequence of either quantum tunneling or multiphoton absorption depending on the laser and material parameters. The quantum tunneling regime, which is dominant in the DC limit and is the relevant regime in this study, is characterized by a threshold field, which must be exceeded in order for ionization to occur. More recently, there has been growing interest in the strong-field physics of correlated quantum materials, with specific focus on Mott insulators [6–13]. When driven with a strong-field pulse, a macroscopic number of elementary charge excitations known as doublons and holes is produced within the insulator [14–21]. The energy required to produce a doublon-hole pair and the Mott gap Δ_{Mott} , along with their correlation length ξ , is central to the

strong-field physics involved since it determines the threshold field required for efficient quantum tunneling,

$$F_{\text{th}} = \Delta_{\text{Mott}}/2\xi, \quad (1)$$

and therefore dictates the field strength beyond which a breakdown of the insulating state occurs.

Recently, we investigated the effect of coupling a Mott insulator to a metal on the doublon production and produced high-order harmonics at the interface [22]. We found that an increased interfacial coupling enhances high harmonic production inside the insulator and suggested an increased doublon-hole correlation length as the reason behind this lowered threshold for response. In the present paper, we aim to verify this claim. We outline a method for extracting the doublon-hole correlation length ξ in Mott insulators that are coupled to a free conducting chain in a metal/insulator interface. The method closely follows that of Oka [14] and relates the *static* parameters ξ and Δ_{Mott} to the *dynamical* rate of charge production Γ in response to a strong-field pulse. Moreover, since Γ was shown to be directly related to the differential reflectivity $\Delta R/R$ [23], an experimental quantity, the method provides

a way of accessing ξ experimentally. We find that an increased interfacial coupling between metal and insulator does in fact lead to an increased correlation length in the insulator, supporting our hypothesis. The result is further tested by comparison with independent *static* DMRG calculations.

2. PROPERTIES OF THE UNCOUPLED MOTT INSULATOR

A popular model exhibiting the Mott insulating phase is the half-filled one-dimensional Hubbard chain:

$$H = -t_0 \sum_{i,\sigma}^L \left(c_{i+1,\sigma}^\dagger c_{i,\sigma} + \text{h.c.} \right) + U \sum_{i,\sigma}^L \left(n_{i,\uparrow} - \frac{1}{2} \right) \left(n_{i,\downarrow} - \frac{1}{2} \right). \quad (2)$$

The model has a known analytic solution given by the Bethe ansatz [24–26]. Charge excitations in this model constitute doubly occupied sites (doublons) and empty sites (holes). Additionally, charge conservation in the model necessitates that doublons and holes are created in pairs. These doublon-hole pairs are the elementary charge excitations in the Hubbard model and are the central focus of our study.

In the $U = 0$ limit the electrons are fully delocalized and, in the ground state, occupy the lower half of a dispersing band $\epsilon(k) = -2t_0 \cos k$, forming a band metal. Since this limit does not energetically distinguish between the four possible states ($|\cdot\rangle, |\uparrow\rangle, |\downarrow\rangle, |\uparrow\downarrow\rangle$) on a given site, the ground state average doublon density is a quarter ($D_{\text{g.s.}} = 1/4$). The charge gap in this limit is zero, and the correlation length diverges. The opposite limit $t_0 = 0$ results in the extreme localization of electrons; no electron is allowed to hop from site to site. The ground state is then a product of singly occupied sites, since double occupancy requires an energy cost on the order of U , while the correlation length becomes very small. For a small finite $t_0 \ll U$, a second-order perturbative correction adds an effective antiferromagnetic exchange $J_{\text{eff}} = 4t_0^2/U$ between nearest-neighbor sites. This can be understood intuitively on the basis of Pauli's exclusion principle. The nonzero hopping t_0 favors electron delocalization via virtual states of neighboring doublons and holes. These virtual hopping processes would be blocked in the case of parallel neighboring spins; thus, antiferromagnetism is favored. In the intermediate regime, the average doublon density will be $0 < D_{\text{g.s.}} < 1/4$. Thus,

$$D_{\text{g.s.}} \equiv \frac{1}{L} \sum_i^L \langle \psi_{\text{g.s.}} | n_{i,\uparrow} n_{i,\downarrow} | \psi_{\text{g.s.}} \rangle \rightarrow 0 \quad (t_0/U \ll 1) \\ \rightarrow 1/4 \quad (t_0/U \gg 1). \quad (3)$$

Applying a large electric field to the Mott insulator can result in dielectric breakdown, during which doublon-hole pairs are produced, marking an increase in $D_{\text{g.s.}}$. It is therefore useful to track $D_{\text{g.s.}}(t)$ as a measure of dielectric breakdown as a driving field is applied.

Finally, we note the analytical expressions for the Mott gap Δ_{Mott} and the correlation length ξ as functions of U/t_0 within the Hubbard model:

$$\Delta_{\text{Mott}}/t_0 = -2 + \frac{U}{2t_0} + 2 \int_0^\infty \frac{d\omega}{\omega} \frac{J_1(\omega) e^{-\frac{U\omega}{4t_0}}}{\cosh \frac{U\omega}{4t_0}}, \\ (\xi/a)^{-1} = \frac{4t_0}{U} \int_1^\infty dy \frac{\ln(y + \sqrt{y^2 - 1})}{\cosh \frac{2\pi t_0 y}{U}}. \quad (4)$$

The quantities are plotted later in Fig. 2(a).

3. DRIVING A METAL-INSULATOR INTERFACE

The model under consideration [Figs. 1(a) and 1(b)] couples the one-dimensional Mott insulator to a metallic chain and to a driving field $F(t) = -\partial A/\partial t$, where

$$A(t) = \frac{F_0}{\omega_0} \sin^2 \left(\frac{\omega_0 t}{2N} \right) \sin(\omega_0 t), \quad (5)$$

where F_0 is the maximum field amplitude and ω_0 is the central frequency. The Hamiltonian is

$$H = -t_0 \sum_{i,\sigma,\alpha}^L e^{-i\phi(t)} c_{i+1,\sigma,\alpha}^\dagger c_{i,\sigma,\alpha} + \text{h.c.} \\ - g \sum_{i,\sigma}^L e^{-i\phi(t)} c_{i,\sigma,A}^\dagger c_{i,\sigma,B} + \text{h.c.} \\ + U \sum_{i,\sigma}^L (n_{i,\uparrow,A} - 1/2)(n_{i,\downarrow,A} - 1/2), \quad (6)$$

where the coupling to the field is introduced by the Peierls substitution $t_0 \rightarrow t_0 e^{-i\phi(t)}$, with $\phi(t) = aA(t)$ and a being the lattice constant. Here we use $a = 4 \text{ \AA}$ and $t_0 = 0.52 \text{ eV}$ to mimic the 1D Mott insulator Sr_2CuO_3 [14,15]. g is the tunable interfacial coupling, and U is the tunable Hubbard repulsion. Equation (6) with $\phi = 0$ was used in [28] to model PdCrO_2 , a magnetic oxide metal displaying Kondo lattice physics.

Let us first discuss the $g = 0$ limit. The response in this limit depends on the dimensionless Keldysh parameter $\gamma_K \equiv \hbar\omega_0/\xi F_0$ and has been studied in [14]. In the tunneling regime, $\gamma_K \ll 1$, the dominant process exciting the charge gap is the electric field F_0 pulling apart doublon-hole pairs and polarizing and breaking down the insulating state. This mechanism is reminiscent of the Schwinger mechanism in vacuum [29], where an electric field large enough ($F_0^{\text{vac}} \gtrsim 10^{18} \text{ V/m}$) will polarize the vacuum, excite the charge gap $\Delta_{\text{vac}} = 2m_e c^2$, and create electron-positron pairs on a much lower energy scale. The rate of pair production becomes exponentially sensitive to the field strength, $\Gamma \propto \exp\{-\pi \frac{F_{\text{th}}}{F_0}\}$, exhibiting a threshold behavior. Here $F_{\text{th}} = \Delta_{\text{Mott}}/2\xi$, explaining the central role both quantities play in strong-field physics. Noting that Δ_{Mott} increases and ξ decreases monotonically (see Fig. 2) with U , we see that breakdown of the insulating state is possible for small U but will fail for larger U as soon as $F_0 < F_{\text{th}}$. For a field

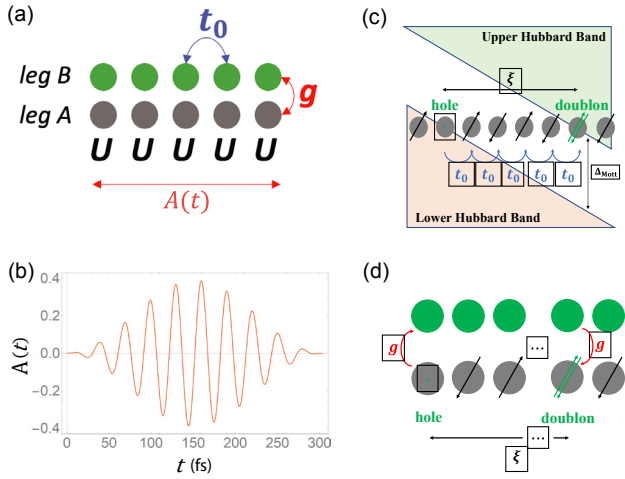


Fig. 1. (a) Model of the coupled metal/Mott-insulator system. (b) Vector potential $A(t)$ as a function of time. (c) In the uncoupled one-dimensional Mott insulator, N hoppings t_0 are required to create a pair of size $\xi = Na$. (d) In the coupled system, a doublon-hole pair of arbitrary size can be created by just two hoppings g as illustrated.

strength $F_0 = 10^9$ V/m, the insulating state is preserved for values $U > U_{th} \sim 6t_0$ [15].

Here, we are always in the tunneling regime with $\gamma_K \ll 1$, where the rate of doublon-hole pair production is

$$\Gamma_{\text{tunnel}} \propto \exp - \left\{ \frac{\pi}{2} \frac{\Delta_{\text{Mott}}}{\xi F_0} \right\}. \quad (7)$$

Electrons must tunnel through a tilted barrier [Fig. 1(c)] to create the doublon-hole pair [14]. As we start coupling the insulator to a metal ($g \neq 0$), entirely new mechanisms of producing the charge excitations emerge [Fig. 1(d)]. The metal leg can now donate an electron on one site while removing an electron from another distant site through just *two* interfacial hoppings g . This is expected to considerably increase the correlation length ξ from the uncoupled insulator limit $g = 0$.

To calculate this increase in ξ we drive the interface with tunable intensity $10^9 \text{ V/m} \leq F_0 \leq 3 \times 10^9 \text{ V/m}$ and central frequency $\omega_0 = 32.9 \text{ THz}$. The whole range of intensities is above F_{th} as evidenced by a finite increase in doublon density by the end of the pulse [see for example Fig. 2(b)]. Since we are in

the tunnel ionization regime [Eq. (7)], we expect that plotting Γ_{tunnel} against F_0^{-1} on a log scale will produce a linear plot with negative slope $-\frac{\pi}{2} \frac{\Delta_{\text{Mott}}}{\xi}$. We can then estimate the value of ξ from the linear fits by assuming that Δ_{Mott} does not change appreciably from its uncoupled value and deduce the effect of coupling g on correlation length ξ .

We calculate the rate of production $\Gamma = dD(t)/dt$ by plotting the ground state doublon density [Eq. (3)] as a function of time, fitting it to a tanh function,

$$D(t) = D_0 + a [\tanh b(t - t_{th}) + 1], \quad (8)$$

and extracting the slope [14]. Figure 2(b) shows $D(t)$ as a function of time for $F_0 > F_{th}$, along with the fitting curve. The maximum production rate can be extracted as $\Gamma = ab$, the slope of the fit at the time of maximum doublon production.

Figure 3 shows log plots of Γ versus F_0^{-1} for small couplings $0.05t_0 \leq g \leq 0.2t_0$ (with increasing coupling down the panels) and $U = 5t_0$. The downward sloping graphs can be fitted with straight lines and ξ extracted from the slope $m = -\frac{\pi}{2} \frac{\Delta_{\text{Mott}}}{\xi}$. We notice that as g is increased, ξ significantly increases even with a very small increase in coupling.

The R-squared values are also calculated for the linear fits as

$$R^2 = 1 - \frac{\sum_i (y_i - f)^2}{\sum_i (y_i - \bar{y})^2}, \quad (9)$$

where y_i are the y -values for the data points, f is the value of the linear fit, and \bar{y} is the average y -value. The values shown for most of the plots in Fig. 3 are close to one, confirming the exponential dependence of charge production on the driving field [Eq. (7)] typical of the tunnel ionization regime.

To verify our results, we conducted independent DMRG calculations which extracted ξ from calculations of the single-particle Green's functions $G(|x|)$. Derived from the charge stiffness, the correlation length is related to the equal time single-particle Green's function $G(|x - x'|) = \langle 0 | c_{x'}^\dagger c_x + c_x^\dagger c_{x'} | 0 \rangle$, which is shown to scale as

$$G(|x|) \sim \exp(-|x|/\xi). \quad (10)$$

This definition of ξ , derived from the Green's function, was used in density matrix renormalization group (DMRG) calculations [30] presented here.

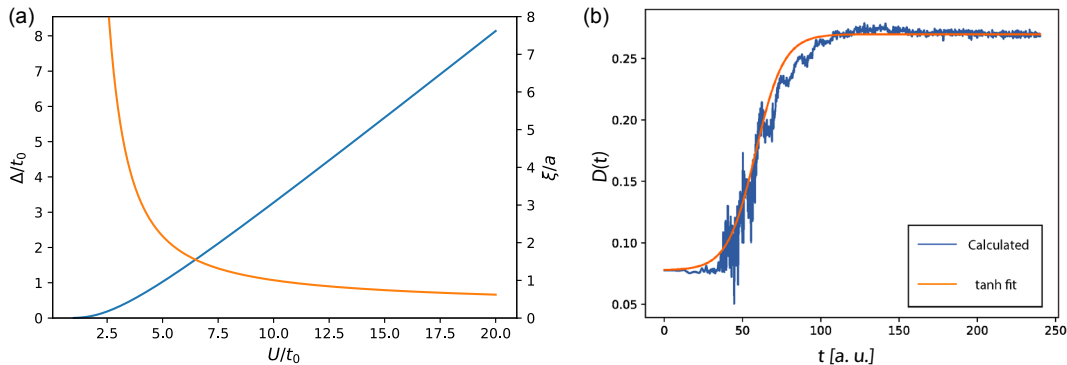


Fig. 2. (a) Mott gap Δ/t_0 [24] (in blue) and doublon-hole correlation length ξ/a [27] (in orange), as functions of Hubbard repulsion U/t_0 . (b) Doublon density as a function of time. $D(t)$ starts at a low value and increases as the pulse ramps up and saturates at a higher value. The curve is fitted to a tanh function [Eq. (8)] to extract the slope [14].

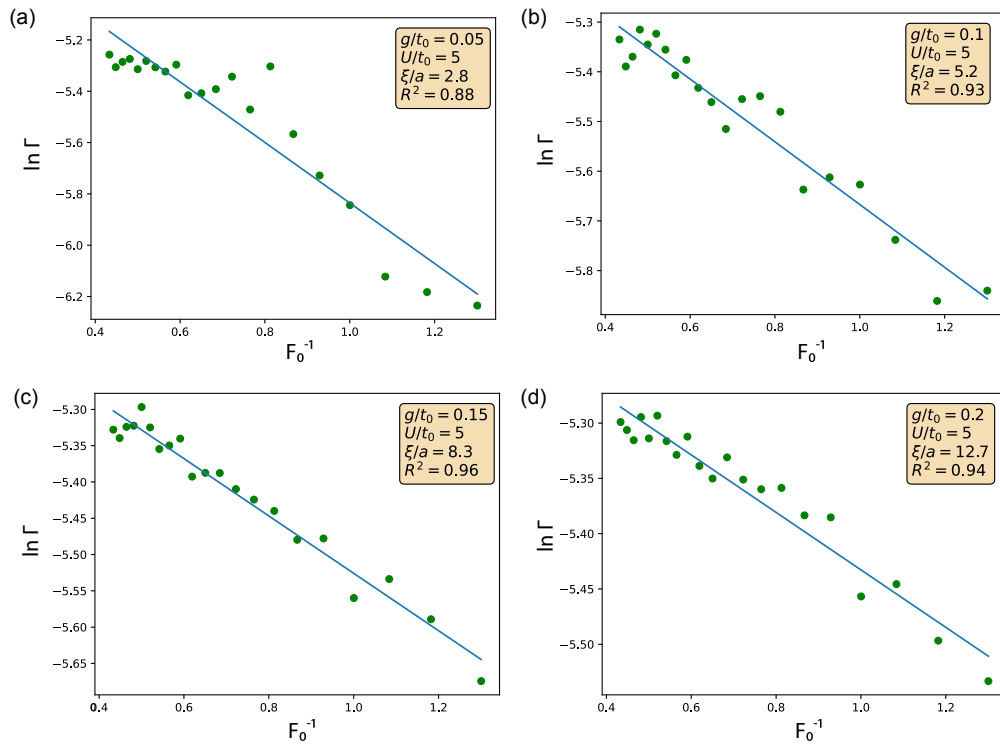


Fig. 3. $\ln \Gamma$ versus F_0^{-1} plots for small couplings $0.05t_0 \leq g \leq 0.2t_0$ (with increasing coupling to the right) for two values of Hubbard $U = 4t_0$ (a)–(d) and $U = 5t_0$ (e)–(h). Notice how even a small coupling to a metal drastically increases the correlation length.

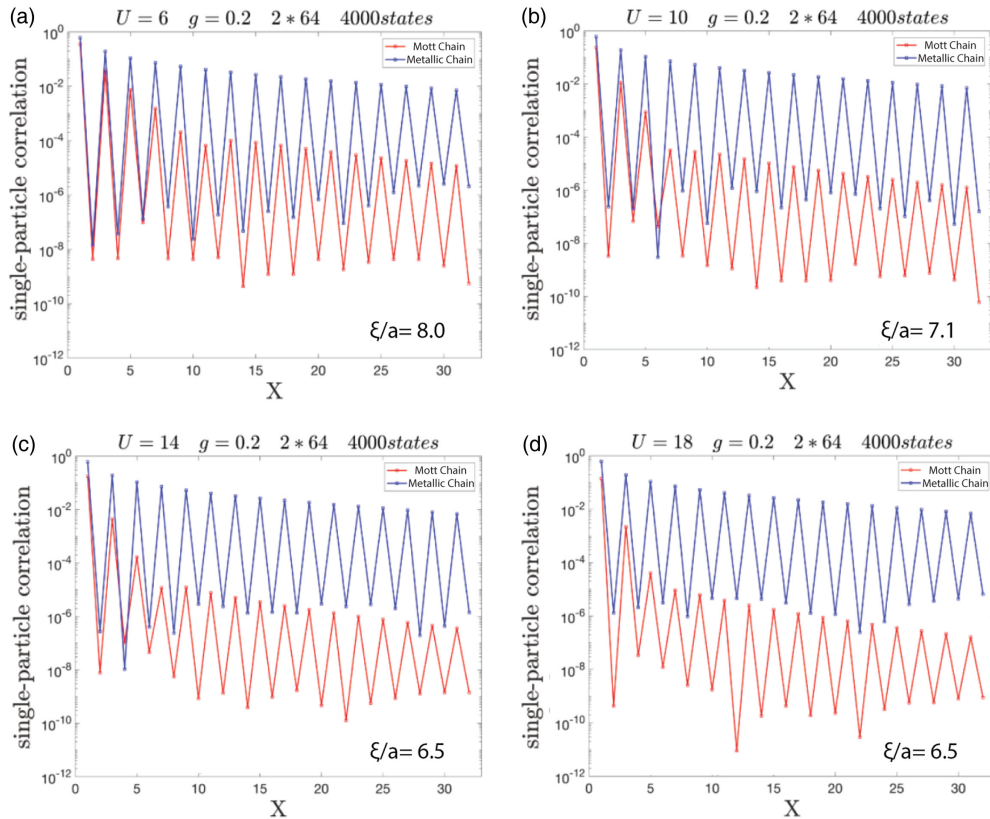


Fig. 4. DMRG results plotting single-particle Green's function versus lattice site for the Hubbard chain (red) and the metallic chain (blue). The interchain coupling $g = 0.2t_0$ for all plots, and the Hubbard value is given on top of each plot. The plots are semi-log, showing the exponential decay of the Green's function and indicating the gapping of the charge mode. We see the usual trend of ξ decreasing with increasing U .

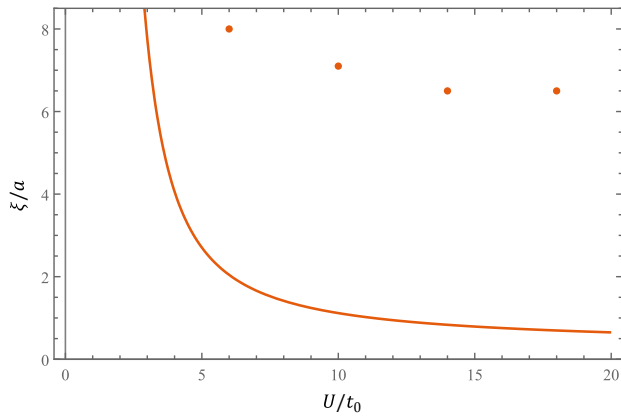


Fig. 5. Correlation length ξ for the uncoupled ($g = 0$) insulator [27] [same as in Fig. 2(a)] and for small coupling $g = 0.2t_0$ from DMRG results.

The geometry of the model considered was extended to a 2×64 ladder with the open boundary conditions, keeping 4096 SU(2) multiplets and discarding weights smaller than 10^{-7} . The results are shown in Fig. 4 for the value of $g = 0.2t_0$ and varying values of U . The plots show $G(|x|)$ for both Hubbard and free chain. The Hubbard chain, which is the focus of our results, shows a linear trend with negative slope in the long-distance behavior. This should be expected as we anticipate $G(|x|) \sim \exp\{x/\xi\}$. From the slope, we can therefore extract ξ . These values are displayed in the bottom-right of each plot and are plotted in Fig. 5 to be compared with $g = 0$, again showing the significant increase in ξ as a result of increasing g . Another observation from Fig. 4 is that while the function $G(|x|)$ slopes down linearly on the whole, it also displays oscillatory behavior on the short length scale with a period equal to $2a$. This can be related to the fact that the lowest energy single-particle excitations in the model occur at $k = \frac{\pi}{2a}$ [31].

4. CONCLUSION

In conclusion, we proposed a method for extracting the doublon-hole correlation length from a highly nonlinear response of a Mott insulator driven by a strong laser field. We then applied this method to demonstrate that the correlation length inside the Mott insulator is significantly increased by the presence of a metallic layer, allowing for an increased mobility of carriers. The tunability of interlayer coupling, g , between the magnetic insulator and the metallic layer could lead to significant advances in the application of Mott insulators as memristors in a neuromorphic network [32,33]. In particular, increasing the coupling value, g , could model long-term potentiation, a key mechanism underlying learning in a neural network, whereby the cell has a lower threshold for a response. In our model, this would correspond to a lowered threshold in the driving electric field needed for the Mott insulator breakdown. As described above, this lower threshold is physically implemented by the increased correlation length with an increasing value of g . The fact that correlation length increases dramatically even for small increases in coupling suggests that this type of control is experimentally feasible and could be mediated by

decreasing the distance between the metallic and insulating layers (by increasing external pressure, for instance).

Furthermore, our work can be used to extract correlation length from experimental measurements of a Mott insulator driven by strong laser fields in the tunneling regime, corresponding to a small value of the Keldysh parameter, γ_K . The relevant experimental observable has to correlate with the rate of doublon-hole production in the tunneling regime, given by Eq. (7). This can be found in high harmonic generation experiments, where it was previously shown that the rate of doublon-hole production correlates closely with the intensity of high harmonics [15,22]. Alternatively, recent experiments measuring differential reflectivity $\Delta R/R$ [23] can also be used to obtain the rate of doublon-hole production, Γ , and thereby extract the doublon-hole correlation length. The ability to extract correlation length directly from experimental data can be used to experimentally validate existing theoretical models of correlated electronic systems.

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Data availability. Data underlying the results presented in this paper are not publicly available at this time but may be obtained from the authors upon reasonable request.

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